

Form PTO-1449

**INFORMATION DISCLOSURE CITATION
IN AN APPLICATION**

(use several sheets if necessary)

DOCKET NUMBER:
8019.103APPLICATION NUMBER:
10/553,229APPLICANT:
Föttinger et al.CONFIRMATION NUMBER:
8967FILING DATE:
October 14, 2005GROUP ART UNIT:
to be assigned**U.S. PATENT DOCUMENTS**

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB-CLASS	FILING DATE IF APPROPRIATE
<i>CL</i>	A	US 4,530,912	07/85	Pullukat et al.	502	104	
	B	US 5,145,821	09/92	Buehler et al.	502	119	
	C	US 6,028,149	02/00	Luciani et al.	526	119	

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	NAME	TRANSLATION	
					YES	NO
<i>CL</i>	AA EP 004 645	10/79	Europe	Karol et al.	n/a	
	AB EP 014 523	08/80	Europe	Gavens et al.	n/a	
	AC EP 027 733	04/81	Europe	Harris et al.	n/a	
	AD EP 089 691	09/83	Europe	Jenkins et al.	n/a	
	AE EP 120 503	10/84	Europe	Karol et al.	n/a	
	AF EP 129 368	12/84	Europe	Ewen et al.	n/a	
	AG EP 241 947	10/87	Europe	Jenkins et al.	n/a	
	AH EP 416 815	03/91	Europe	Stevens et al.	n/a	
	AI EP 420 436	04/91	Europe	Canich	n/a	
	AJ EP 494 084	07/92	Europe	Kioka	n/a	
	AK EP 594 915	05/94	Europe	Diare et al.	n/a	
	AL WO 91/07443	05/91	WIPO	Kostainen et al.	n/a	
	AM WO 91/16361	10/91	WIPO	Ala-Huikku et al.	n/a	
	AN WO 97/04015	02/97	WIPO	Govoni et al.	n/a	
	AO WO 97/48742	12/97	WIPO	Denton et al.	n/a	
	AP WO 98/03559	01/98	WIPO	McLain et al.	n/a	
	AQ WO 98/22486	05/98	WIPO	Ewen et al.	n/a	
	AR WO 98/27124	06/98	WIPO	Bennett	n/a	
	AS WO 99/46306	09/99	WIPO	Pullukat et al.	n/a	
	AT WO 03/54028	07/03	WIPO	Föttinger et al.	n/a	

OTHER DOCUMENTS

EXAMINER INITIAL		AUTHOR	DOCUMENT
<i>CL</i>	BA	Brunauer et al.	"Adsorption of Gases in Multimolecular Layers", J. Am. Chem. Soc., pp 309-319 (1938)
	BB	Luo et al.	"Studies on the Formation of New, Highly Active Silica-Supported Ziegler-Natta Catalyst for Ethylene Polymerization", J. Catalysis 210, pp328-339 (2002)

EXAMINER	DATE CONSIDERED
<i>Rixie Lu</i>	3-21-07

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP §609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.